

Amendments to the Drawings:

The attached sheet of drawings includes changes to FIG. 1. This sheet, which includes FIG. 2, replaces the original sheet including FIGS. 1 and 2. Specifically, FIG. 1 has been revised to add reference numeral --1-- with appropriate lead line.

A full set of replacement drawings is attached.

REMARKS

The as-filed specification has been amended to correct minor typographical errors. FIG. 1 has been amended to include a lead line. No new matter has been added.

The Office Action mailed August 27, 2007, has been received and reviewed. Claims 29 through 48 are currently pending in the application, of which claims 33 through 39 are currently under examination. Claims 29 through 32, and 40 through 48 are withdrawn from consideration as being drawn to a non-elected invention, and have been canceled. Claims 33 through 39 stand rejected.

Applicants have amended claims 33 and 34 only to improve the form thereof and enhance antecedent basis, and respectfully request reconsideration of the application as amended herein.

Double Patenting Rejection Based on U.S. Patent No. 6,057,638

Claims 33 through 39 stand rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1 through 7 of U.S. Patent No. 6,057,638. In order to avoid further expenses and time delay, Applicants elect to expedite the prosecution of the present application by filing a terminal disclaimer to obviate the double patenting rejections in compliance with 37 CFR ' 1.321 (b) and (c). Applicants' filing of the terminal disclaimer should not be construed as acquiescence in the Examiner's double patenting or obviousness-type double patenting rejections. Attached are the terminal disclaimer and accompanying fee.

CONCLUSION

Claims 33 through 39 are believed to be in condition for allowance, and an early notice thereof is respectfully solicited. Should the Examiner determine that additional issues remain which might be resolved by a telephone conference, the Examiner is respectfully invited to contact Applicants' undersigned attorney.

Respectfully submitted,



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Date: November 26, 2007

TH/dlm:ec:csw

Attachments: Appendix A: Clean version of the substitute specification
Appendix B: Marked-up version of the substitute specification
Appendix C: Replacement Sheets (2 sheets) and Annotated Sheet Showing
Changes Made (1 sheet)

Document in ProLaw

APPENDIX B

**(VERSION OF SUBSTITUTE SPECIFICATION
WITH MARKINGS TO SHOW CHANGES MADE)**

(Serial No. 09/489,286)

PATENT
Attorney Docket 2269-7129.2US (95-0582.02)

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APPLICATION FOR LETTERS PATENT

for

A FIELD EMISSION DISPLAY WITH LOW WORK FUNCTION EMITTERS

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A FIELD EMISSION DISPLAY WITH LOW WORK FUNCTION EMITTERS

GOVERNMENT RIGHTS

[0001] This invention was made with government support under Contract No. DABT 63-93-C0025 awarded by Advanced Research Projects Agency (ARPA). The government has certain rights in this invention.

~~Cross reference to Related Application~~ CROSS-REFERENCE TO RELATED APPLICATIONS

[0002] This application is a divisional of ~~serial no.~~ United States Patent Application Serial No. 09/105,613, filed June 26, 1998, now U.S. Patent 6,057,638, issued May 2, 2000, which is a divisional application of ~~serial no.~~ United States Patent Application Serial No. 08/543,819, filed October 16, 1995, now U.S. Patent No. 5,772,488, issued June 30, 1998, the contents of which is- are hereby expressly incorporated by reference for all purposes.

BACKGROUND OF THE INVENTION

[0003] This invention relates to field emission ~~displays, and~~ displays and, more ~~particularly~~ particularly, to the formation of low work function emitters.

[0004] The required turn-on voltage for an emitter at a constant current is a function of the work function of the material at the surface of the emitter. For example, see U.S. Patent No. 4,325,000, issued April 13, 1982, incorporated herein by reference, and H.B. Michaelson, ~~H.B.~~ "Relation Between An Atomic Electronegativity Scale and the Work Function," 22 IBM Res. Develop., No. 1, Jan. 1978. Reduction of the work function of a material can be achieved by coating the surface with an electropositive element. For example, see U.S. Patent No. 5,089,292, incorporated herein by reference. However, such knowledge has never been translated into a useful field emission display. Electropositive materials are very ~~reactive~~, reactive and, therefore, upon coating on an emitter, they quickly begin to react with most atmospheres, resulting in a high work function material coating the emitter. ~~Accordingly~~ Accordingly, emitters coated with low work function materials on the surface have traditionally not been useful. Also, the compositions in which electropositive elements normally exist (for example, as a salt with Cl) include elements that have a very large work function (~~e.g.~~ e.g., Cl).

[0005] The present invention provides solutions to the above problems.

SUMMARY OF THE INVENTION

[0006] According to one aspect of the invention, a field emission display is provided comprising: an anode; a phosphor located on the anode; a cathode; an evacuated space between the anode and the cathode; an emitter located on the cathode opposite the ~~phosphor~~; phosphor, wherein the emitter comprises an electropositive ~~element~~ element, both in a body of the emitter and on a surface of the emitter.

[0007] According to another aspect of the ~~invention~~ invention, a process for manufacturing ~~an~~ a FED is provided comprising the steps of: forming an emitter comprising an electropositive element in the body of the tip; positioning the emitter in opposing relation to a phosphor display screen; creating an evacuated space between the emitter tip and the phosphor display screen; and causing the electropositive element to migrate to ~~the an~~ an emission surface of the emitter.

DESCRIPTION OF THE DRAWINGS

[0008] For a more complete understanding of the present invention and for further advantages thereof, reference is made to the following Detailed Description taken in conjunction with the accompanying drawings, in which:

[0009] Fig. 1 is a side view of an embodiment of the present invention.

[0010] Fig. 2 is a side view of a detailed area of Fig. 1.

[0011] Fig. 3 is a side view of an alternative embodiment ~~to the embodiment~~ of the invention as seen in Fig. 1.

[0012] It is to be noted, however, that the appended drawings illustrate only typical embodiments of this invention and ~~are therefore~~ are, therefore, not to be considered limiting of its scope, for the invention may admit to other equally effective embodiments.

DETAILED DESCRIPTION

[0013] Referring now to Fig. 1, a field emission display 1 according to the present invention is shown comprising: an anode 10, which in this embodiment comprises a faceplate, or screen of the field emission display. This embodiment further comprises a phosphor

screen 12, located on the anode 10; a cathode 14, attached to anode 10 by glass frit 15; and an evacuated space 16 between the anode 10 and the cathode 14.

[0014] Referring now to Fig. 2, a more detailed view of cathode 14 in the region of circle A of Fig. 1 is seen comprising: an emitter tip 18 located on the cathode 14 opposite the phosphor screen 12. In this embodiment of the invention, the emitter tip 18 comprises an electropositive element 20 both in a body 18a of the emitter tip 18 and on a surface 18b of the emitter tip 18. Spaced from emitter tip 18 by dielectric 19 is grid electrode 17. In this embodiment, the distribution of the electropositive element 20 in the body 18a of the emitter tip 18 is substantially even. However, according to an alternative embodiment, the distribution ~~is~~ may be more uneven, wherein ~~there is a~~ may be a gradient of the electropositive element 20 in the body 18a and the surface 18b is substantially all electropositive element 20. According to one specific embodiment, the distribution is an exponential change, and the electropositive ~~element~~ element 20 is provided in the body 18a such that the work function of the surface 18b of emitter tip 18 is reduced by at least ~~50 %~~ 50%. For example, in the case of an amorphous silicon emitter tip, the work function is 3.9 eV without an electropositive component, and about 2.0 eV if Na is doped according to the dip process described below.

[0015] Acceptable specific elements for electropositive element 20 are chosen from groups IA, IIA, IIIA and ~~IIIA~~ IIIB of the periodic table. One specific element known to be useful as electropositive element 20 comprises Cs. Another element known to be useful comprises Na. Others known or believed to be useful comprise: H, Li, Be, B, Mg, Al, Ga, Ba, Rb, Ca, K, Sr, and In.

[0016] An example process for manufacturing a field emission display ("FED") according to the present invention comprises the steps of: forming an emitter tip 18 comprising an electropositive element 20 in the body 18a of the emitter tip 18; positioning the emitter tip 18 in opposing relation to a phosphor screen 12 on the display; creating an evacuated space 16 between the emitter tip 18 and the phosphor screen 12; causing the electropositive element 20 to migrate to the emission surface 18b of the emitter tip 18, whereby the display of Fig. 2 results.

[0017] According to an example process of forming the emitter tip as in Fig. 2, the emitter tip 18 is formed by methods that will be understood by those of skill in the art (for example, see U.S. Patent Nos. 4,940,916; 5,391,259; and 5,229,331, all of which are incorporated herein by reference), and the substrate with the emitter tip 18 is contacted with a

solution in a glass container. The solution comprises an electropositive element as the solute, and a solvent (for example, alcohol). Other solvents believed to be useful according to other embodiments of the invention include: water, acetone, or any other solvent capable of dissolving electropositive salts.

[0018] As mentioned above, said electropositive element comprises an element chosen from groups IA, IIA, ~~IIIA~~ and ~~IIIA- IIIB~~ of the periodic table. One specific element known to be useful ~~as~~ as an electropositive element comprises Cs. Others known or believed to be useful comprise: H, Li, Be, B, Na, Mg, Al, Ga, Ba, Rb, Ca, K, Sr, and In.

[0019] According to one example of the present invention, the contacting comprises dipping the emitter tip into the solution for a time sufficient to cause 10^{21} atoms/cm³ of electropositive material to penetrate into the emitter tip. Some acceptable solutions, dip times, and dip temperatures are listed below (other examples will occur to those of skill in the art):

Solution Composition	Dip Time	Dip Temperature (Degrees C)
propan-1-ol solvent - NaCl solute	15 minutes	82
methanol solvent - CsCl solute	15 minutes	62
ethanol solvent - NaCl solute	15 minutes	75
methanol solvent - NaCl solute	15 minutes	62
propan-1-ol solvent - CsCl solute	15 minutes	82
ethanol ethanol solvent - CsCl	15 minutes	75

[0020] In a more specific embodiment, a silicon substrate from which the emitters have been shaped is dipped in a solution of propan-2-ol, as the solvent, and CsCl, the solution being kept just under the boiling temperature. Next, either amorphous silicon (a-Si) or micro crystalline silicon (u-Si) is deposited at between about 200 degrees C and about 300 degrees C (for example, by ~~plasma-enchanted~~ plasma-enhanced chemical vapor deposition). Thus, the Cs layer is protected from reaction with other elements by the silicon deposition during further handling. Once the display is ready for assembly, the various components of Fig. 1 are brought together in a vacuum, and then sealed and heated. Since in a-Si and u-Si the density of surface states is high, most of the Cs atoms will migrate to the surface of emitter tip 18 and be trapped right at the surface of the deposited films, where a cesium rich monolayer 20a is created, as shown in FIG. 2.

[0021] In another specific embodiment, a glass substrate with 7000 angstrom amorphous-silicon emitters formed thereon was dipped in a solution of propan-1-ol, as the solvent, and NaCl for 15 minutes at a temperature just below boiling. The result was an approximately 7000 angstrom alpha-silicon/glass structure with Na doped therein. SIMS analysis of H, P, and Na were conducted comparing a similar sample ~~which~~ that had not been dipped. The NaCl dipped structure had about 500 times higher Na near the Si surface (at about 500 angstroms depth) than the sample ~~which~~ that had not been dipped. The Na level remained higher throughout the 7000 angstroms tested, but decreased to about 80 times higher near the Si/glass interface (at about 6000 angstroms). Further, the dipped sample included a slightly higher P than the undipped sample, but the difference was less than about 1.5 times. No H difference was seen between the samples. Mo contamination (due to use of a furnace having MO therein) was detected on the NaCl dipped sample, but no Mo was seen in the undipped sample. Mo contamination is avoided in other embodiments. Higher K and Ca were also observed in the NaCl dipped sample. Surprisingly, Cl was not detected in either the dipped or undipped sample. This is an important finding as Cl has a high work function and is undesirable in the emitter tip.

[0022] According to ~~still~~ a further embodiment, the emitter tip is made after the substrate from which the emitter tip is formed is doped with an electropositive element. For example, according to one alternative embodiment of the invention, the substrate on which the emitter tip is manufactured is dipped, before the formation of the emitter tip, and the emitter tip is then formed on the substrate. According to specific examples of processes believed to be acceptable according to this embodiment, the following parameters are used:

Solution Composition	Dip Time	Dip Temperature (Degrees C)
propan-1-ol solvent - NaCl solute	15 minutes	82
methanol solvent - CsCl solute	15 minutes	62
ethanol solvent - NaCl solute	15 minutes	75
methanol solvent NaCl solute	15 minutes	62
propan-1-ol solvent - CsCl solute	15 minutes	82
ethanol solvent - CsCl solute	15 minutes	75

[0023] According to ~~still~~ a further embodiment, plasma-enhanced chemical vapor deposition is used to place the electropositive element in the body of the emitter tip. As before, the vapor deposition is conducted either before or after the formation of the emitter tip. After the vapor deposition, heating will cause diffusion of the electropositive element into the body of the emitter tip. After assembly in an evacuated space, subsequent heating causes the material to migrate to the surface of the emitter tip, where it will not react due to the vacuum, and a low work function emitter tip is thereby achieved.

[0024] Another acceptable method of placement of the electropositive element in the body of the emitter tip is through ion-implantation, again followed by heating after evacuation to cause diffusion.

[0025] In embodiments in which the electropositive element is applied before the emitter tip is formed, some of the electropositive element will be exposed during subsequent steps, such as etching. When this occurs, an oxide or non-volatile salt will form, depending upon the atmosphere at the surface of the emitter tip when exposure occurs. In these embodiments, the oxide or non-volatile salt ~~which is rinsed (for~~ is rinsed, for example, with buffered oxide etchant in the case of oxide or water in the case of ~~salt)~~, salt, before further processing. Acceptable examples of materials for the substrate ~~which~~ that is doped with the electropositive element include, for example, Si, Mo, Cr, and W. Others will occur to those of skill in the art.

[0026] Other steps to form the emitter tip and other structures of the FED will be understood by those of skill in the art and require no further explanation here.

[0027] According to some embodiments (for example, see Fig. 3), the display is sealed by glass frit seal 33, chosen to match the thermal expansion characteristic of the cathode 35, which, in this embodiment, comprises a glass substrate 37 on which emitters 39 are formed. This embodiment is particularly useful for large area displays. The sealing is done in a vacuum space by heating the entire device. The heating to a seal temperature for the frit 33 (for example, 450 degrees C for a ~~lead glass based frit~~), lead-based glass frit) causes the migration of the electropositive element 20 (see FIG. 2) to the surface of the emitters 39.

[0028] According to ~~still~~ a further embodiment, seen in Fig. 1, the cathode 14 is encased by a backplate 50, which is also sealed in vacuum by a frit 51 by heating. This embodiment is useful in small area displays where, for example, the cathode 14 comprises a

silicon substrate onto which the ~~emitters~~ emitter tips 18 are formed. Here, the cathode 14 is attached to faceplate 10 by another glass frit seal 15, also sealed by heating.

ABSTRACT

According to one aspect of the invention, a field emission display is provided comprising: an anode; a phosphor screen located on the anode; a cathode; an evacuated space between the anode and the cathode; an emitter located on the cathode opposite the phosphor; wherein the emitter comprises an electropositive element both in a body of the emitter and on a surface of the emitter. According to another aspect of the ~~invention~~ invention, a process for manufacturing ~~an FED~~ a FED is provided comprising the steps of: forming an emitter comprising an electropositive element in the body of the tip; positioning the emitter in opposing relation to a phosphor display screen; creating an evacuated space between the emitter tip and the phosphor display screen; and causing the electropositive element to migrate to ~~the an~~ an emission surface of the emitter.